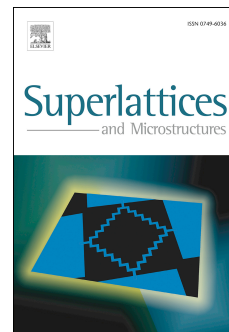


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Tunable growth of semiconductor nanostructures by Plasma Enhanced Chemical Vapor Deposition - Synthesis, morphological and Raman studies

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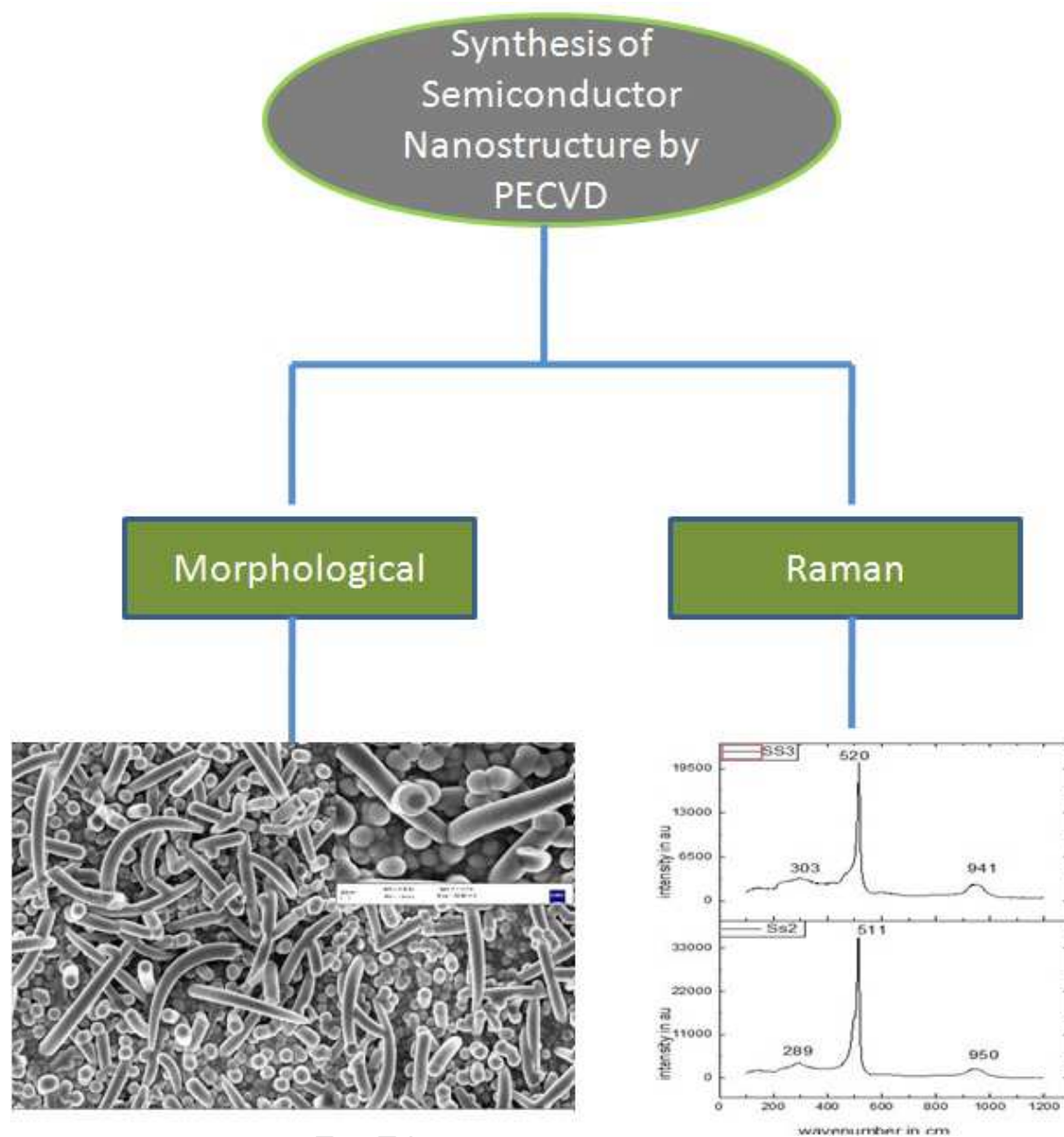
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